

# ORDERED SUPRAMOLECULAR POLYTHIOPHENE STRUCTURES ON PASSIVATED SILICON SURFACES

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# Background

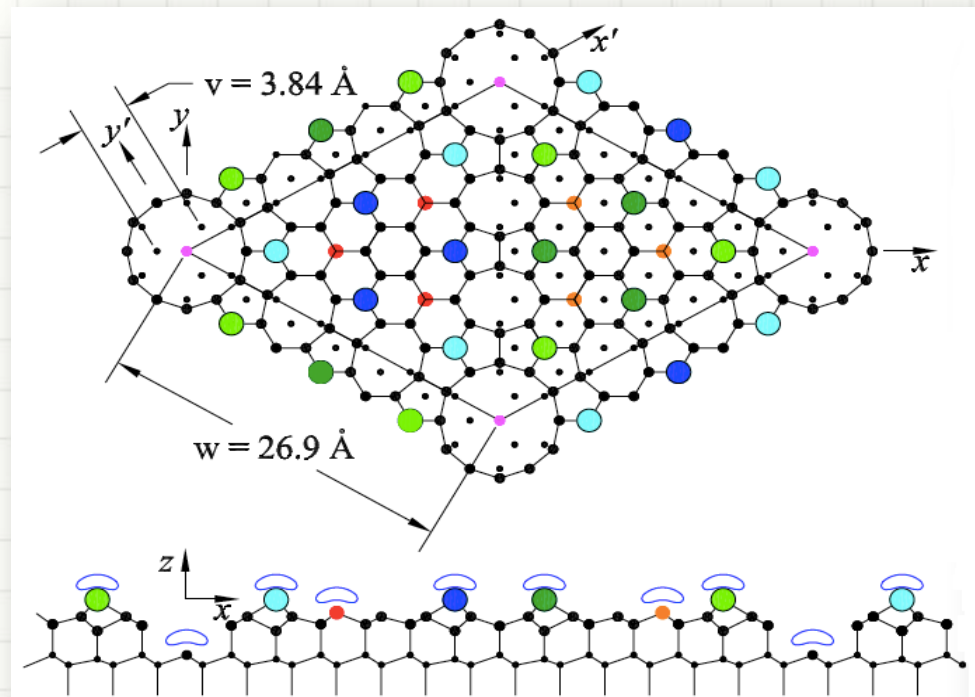
- The functionalization of semiconductor surfaces with organic molecules is a necessary step in the development of hybrid organic-semiconductor structures.
- A significant challenge to organic layer formation is the fact that semiconducting surfaces exhibit a large number of dangling bonds which suppress the diffusivity of adsorbed molecules and can even break the molecules apart via the formation of Si-C bonds.
- Recently it has been shown that these problems can be overcome by depositing the molecules onto a passivated surface.\*

\*Suzuki et al. Phys. Chem. Chem. Phys., 2009, 11, 6498–6504

# Silicon Substrate

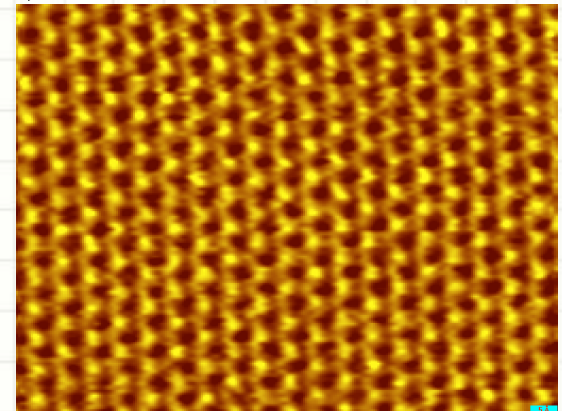
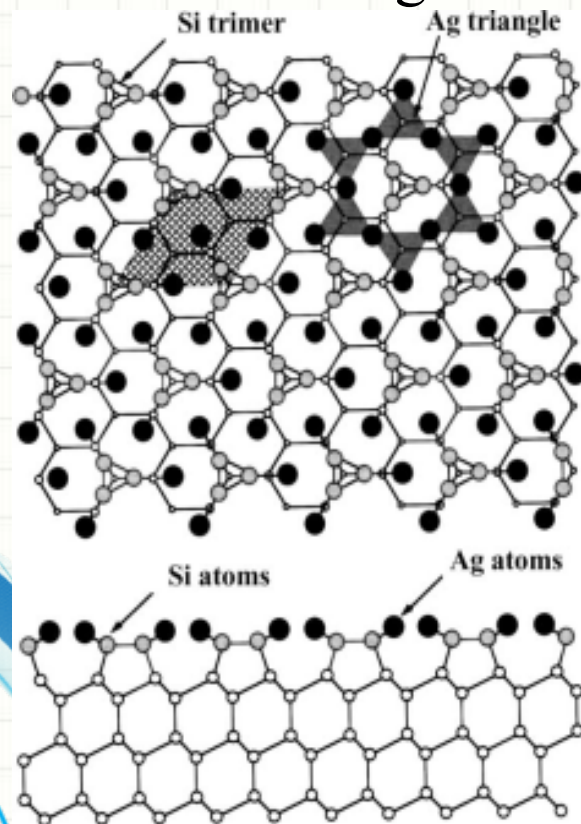
Si(111) has a complex stable  $7 \times 7$  reconstruction, which reduces the number of dangling bonds from 49 to 19 for each  $7 \times 7$  unit cell.

**Still not good enough!  
Can't provide a surface  
with enough mobility for  
molecule diffusion.**



# $\sqrt{3}$ surface

Compared to the highly reactive Si(111) ( $7 \times 7$ ) surface, a monolayer Ag layer passivates the surface which allows the supramolecular ordering of TPA on Si(111).\*



STM image of the  $\sqrt{3}$ -Ag surface.  
 $100\text{\AA} \times 100\text{\AA}$

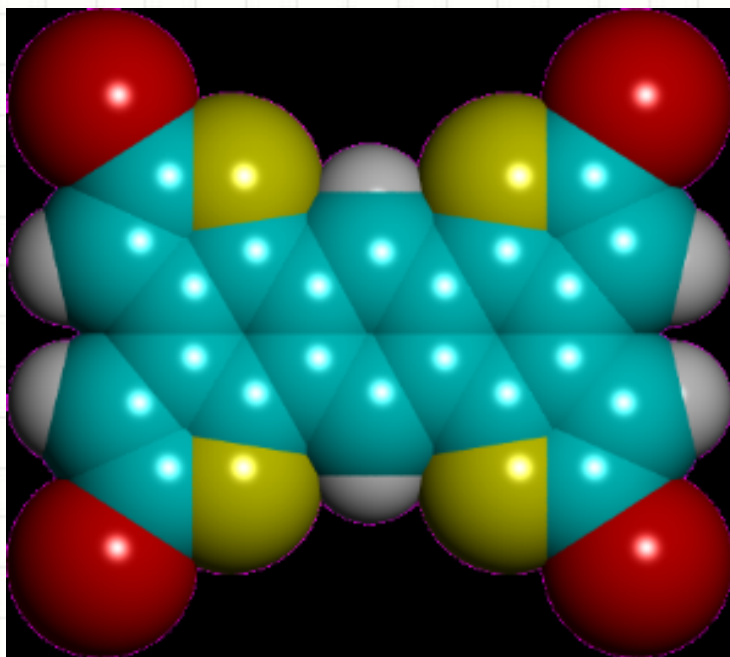
Atomic structure of  $\sqrt{3}$  Ag reconstruction.  
Reproduced from X. Tonga et al.;  
Applied Surf. Sci. 190,121 (2002).

\*Suzuki et al. Phys. Chem. Chem. Phys., 2009, 11, 6498–6504



# Thiophene Deposition

- Thiophene based molecules are of considerable interest in organic semiconductor research due to their efficient conjugation and the chemical stability.
- Thiophene thin films exhibit reasonably high mobilities ( $\mu_h \sim 2 \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$ )\*
- In addition to non-conjugated layers, thiophene based molecules have been used as precursors in surface-confined polymerization experiments.



Tetrabromo-  
tetrathienoanthracene  
(TBTTA)

Red: Bromine

Blue: Carbon

Yellow: Sulfur

White: hydrogen

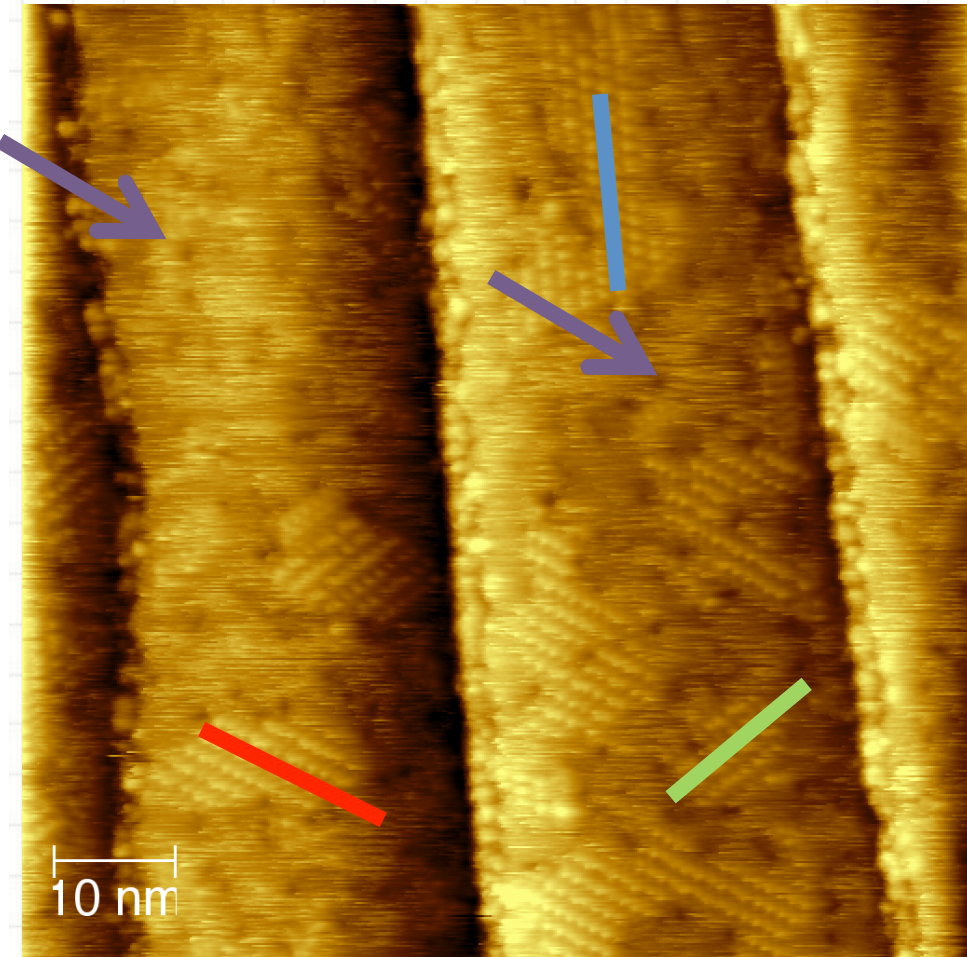
\*Takimiya et al., J.AM.CHEM.SOC.128, 2006 12605



# Experiment

- All measurements are performed in UHV system with a base pressure  $\sim 2 \times 10^{-10}$  Torr.
- Si(111) wafers use a annealing sequence to attain  $7 \times 7$  reconstruction.
- The  $\sqrt{3}$  surface is formed by deposition of one monolayer of silver onto the clean Si surface at 580 °C. Layer formation confirmed with low energy electron diffraction (LEED).
- TBTTA molecules deposited and Auger electron spectroscopy (AES) was used to verify the coverage.

# Supramolecular structures at RT

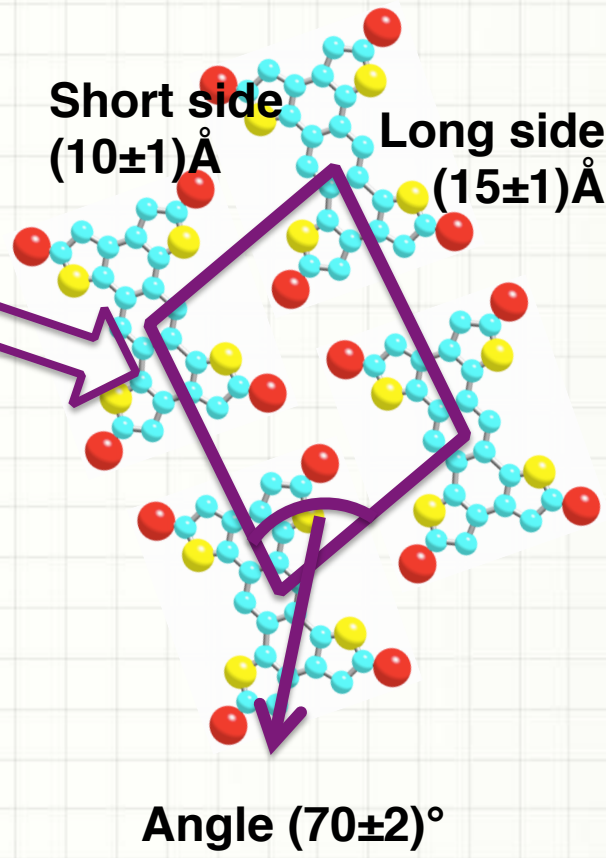
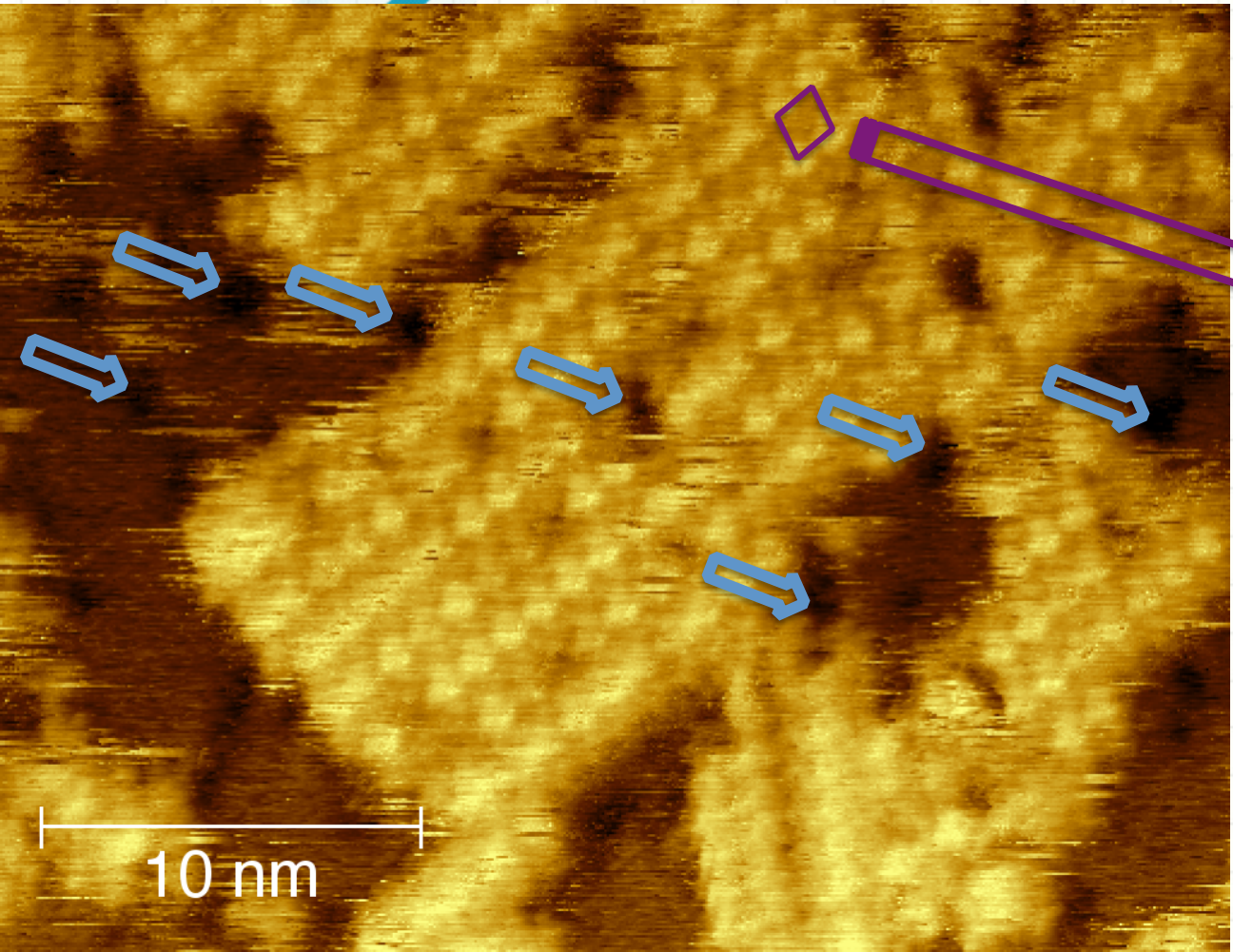


770Å×770Å (-1.2 V 110 pA)

- Three supramolecular domains consistent with the 3-fold symmetry of  $\sqrt{3}$  lattice
- “Raster noise” in many images suggest additional molecules moving on the surface
- Structures only stable under certain bias conditions



# Unit Cell

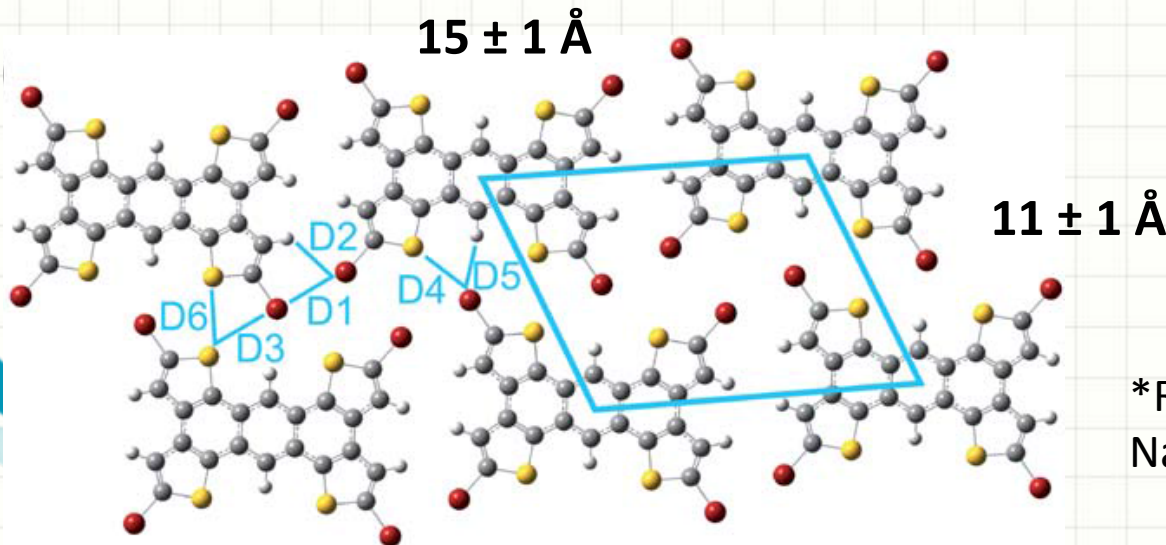


320Åx320Å (-1.11 V 500 pA)



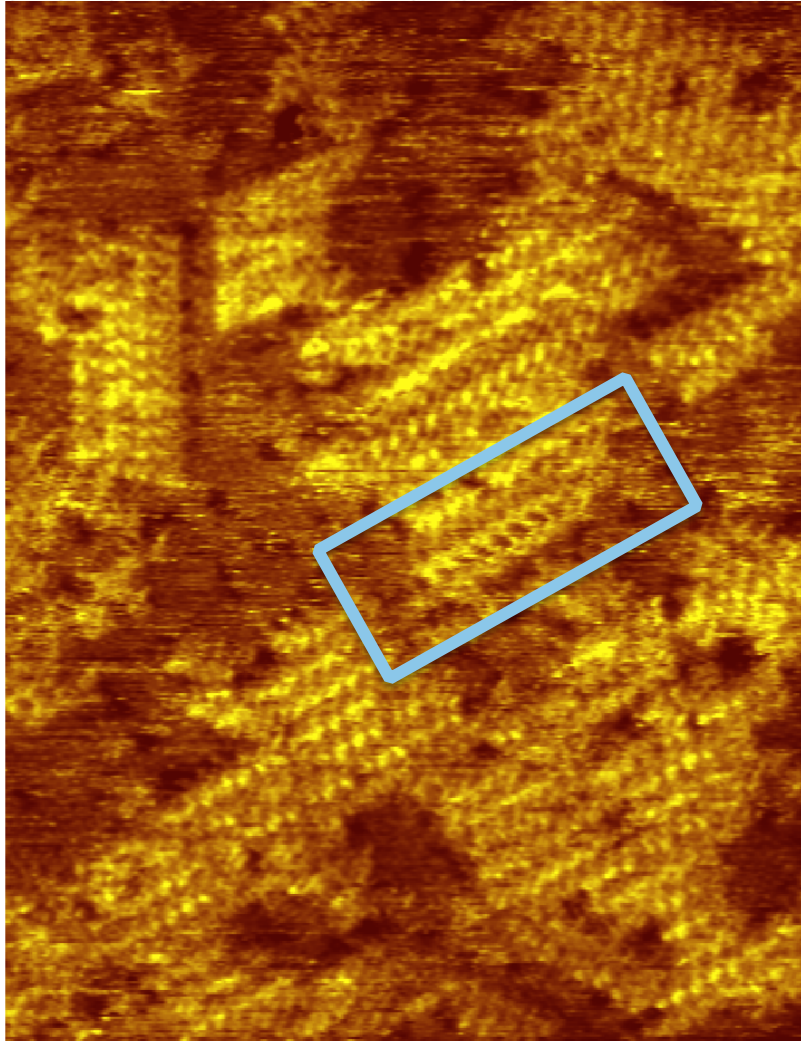
# Intermolecular Interactions

- TBTTA on Highly oriented pyrolytic graphite (HOPG) exhibits very similar unit cell\*
- On HOPG, DFT calculations indicate ordering determined entirely by Van der Waals interactions between molecules.



\*Rico Gutzler et al.  
Nanoscale, 2012, 4, 5965–5971

# Type II structures at RT



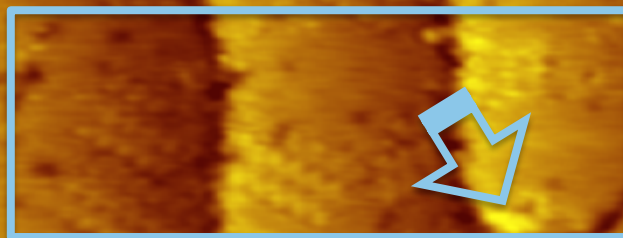
- Do observe second (type II) structures at RT
- The periodicity is  $(9 \pm 0.5) \text{ \AA}$
- More stable under range of bias conditions

350Å×500Å (1.03 V 480 pA)

# Effect of annealing

- Silver layer limits temperature to 400°C
- Above 160°C molecular layer decomposes

144°C



Auger indicates no stoichiometric change after anneal at this temperature.

640Å×425Å (1.2 V 300 pA)

300Å×150Å (1.2 V 300 pA)



# Summary:

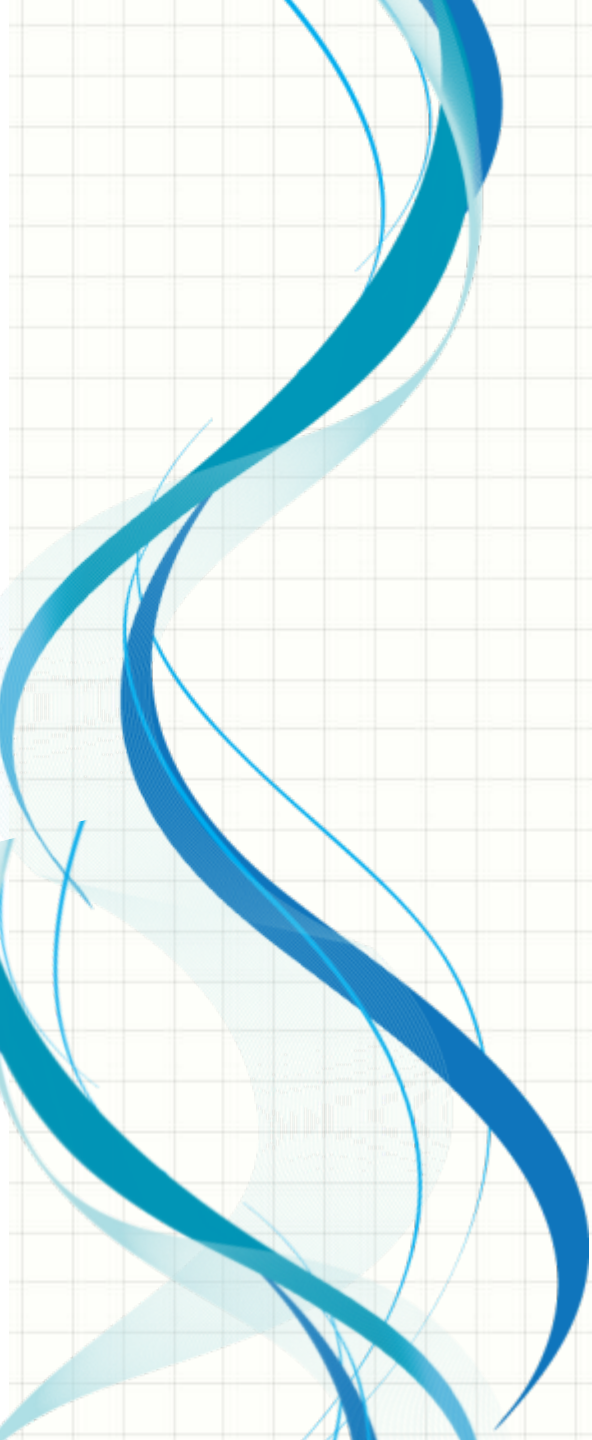
- The  $\sqrt{3}$  surface does provide a high mobility template for TBTTA adsorption.
- Molecules form 2-d structures on  $\sqrt{3}$  surface at RT. Structures are quite fragile and can decompose readily under STM imaging.
- Size and symmetry of unit cell suggests Van der Waals interaction the driving force.
- Defects in  $\sqrt{3}$  structure can limit the size of domains.
- Another (type II) structure observed at room temperature.
- Do see changes after annealing.

**THANK YOU  
FOR YOUR ATTENTION!**

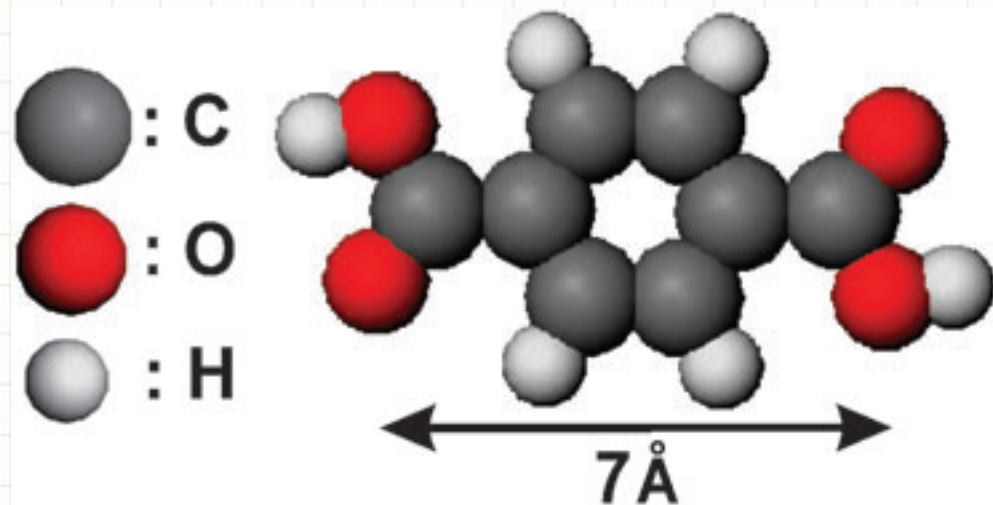
Financial supported by



**NSERC  
CRSNG**







Molecular structure of terephthalic acid (TPA).

# Possible covalent structure

A recent research indicated that a Ullman dehalogenation reaction followed with C-C coupling can be performed on Ag(111) surface after the absorption of TBTTA when thermal energy was applied.\*

